

**REMARKS**

Favorable reconsideration and allowance of the present application are respectfully requested in view of the following remarks. Claims 1, 2, 4, 7, and 11 have been amended. No new matter has been entered. Claims 5 and 13 are currently cancelled and claims 3, 6, 17-27 and 30-32 had previously been cancelled. Claims 33 and 34 are currently added. Thus, claims 1, 2, 4, 7-12, 14-16, 28-29 and 33-34 are pending for consideration.

**35 U.S.C. § 103 REJECTION**

Claims 1-2, 4-5, 7-16, and 28-29 stand rejected under 35 U.S.C. § 103(a) as being unpatentable over Evans et al. (U.S. Patent No. 6,001,515, hereinafter "Evans") in view of Kondo et al. (Japanese Patent Publication No. 09-318805, hereinafter "Kondo"). Applicant respectfully traverses this rejection.

Independent claim 1 is allowable at least in that this claim recites a combination of elements, including, for example, "providing a substrate on which a plurality of unit panels and etching object layers on the respective unit panel areas are formed, each of the unit panels including a plurality of gate lines and data lines defining a plurality of pixels, a thin film transistor in each pixel, and a pixel electrode in each pixel", "transferring the resist in the grooves of one divided portion of the cliché on a blanket applied on a surface of a printing roll by contacting and rotating the printing roll with one divided portion of the cliché, the printing roll corresponding to respective the unit panel of the substrate", and "applying the resist transferred on the surface of the blanket of the printing roll on the etching object layer on a corresponding unit panel of the substrate." None of the cited references, singly or in combination, teach or suggest at least these features of the claimed invention.

Accordingly, Applicant respectfully submits that claim 1 and claims 2, 4, 7-10, 28 and 33-34, which depend directly and indirectly from claim 1, are allowable over the cited references.

Independent claim 11 is allowable at least in that this claim recites a combination of elements, including, for example, "providing a substrate on which a plurality of unit panels and etching object layers on the respective unit panel areas are formed, each of the unit panels including a plurality of gate lines and data lines defining a plurality of pixels, a thin film transistor in each pixel, and a pixel electrode in each pixel", "transferring the resist filled in the groove of the one of divided areas of the cliché onto a surface of the blanket on the printing roll by contacting and rotating the printing roll with the one of divided areas of the cliché corresponding to the unit panel of the substrate" and "applying the resist transferred on the surface of the blanket on the etching object layer on the unit panel of the substrate corresponding to the one of divided area of the cliché." None of the cited references, singly or in combination, teach or suggest at least these features of the claimed invention.

Accordingly, Applicant respectfully submits that claim 11 and claims 12 and 14-16 and 29, which depend directly and indirectly from claim 11, are allowable over the cited references.

#### Claims Added

Applicants submit that new claims 33 and 34 depend from independent claim 1, and are therefore allowable based on their dependence. In addition, claims 33 and 34 recite further limitations which are not disclosed or made obvious by the applied prior art references. Consideration and allowance of claims 33 and 34 are respectfully requested

Conclusion

All of the stated grounds of rejection have been properly traversed, accommodated, or rendered moot. Applicant therefore respectfully requests that the Examiner reconsider all presently outstanding rejections and that they be withdrawn. It is believed that a full and complete response has been made to the outstanding Office Action, and as such, the present application is in condition for allowance.

The Examiner is respectfully requested to enter this Amendment After Final, in that it raises no new issues but merely places the claims in a form more clearly patentable over the references of record. In the alternative, the Examiner is respectfully requested to enter this Amendment After Final in that it reduces the issues for appeal.

If the Examiner believes, for any reason, that personal communication will expedite prosecution of this application, the Examiner is invited to telephone Jun S. Ha, Registration No. 58,508, at (703) 205-8000, in the Washington, D.C. area.

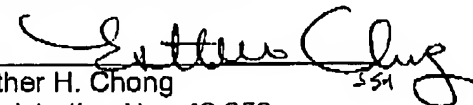
Prompt and favorable consideration of this Amendment is respectfully requested.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayment to Deposit Account No. 02-2448 for any additional fees required under 37 C.F.R. §§ 1.16 or 1.17; particularly, extension of time fees.

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Respectfully submitted,

By



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